The eBeam Initiative provides a forum for educational and promotional activities regarding new semiconductor manufacturing approaches based on electron beam (eBeam) technologies. Its goals are to reduce the barriers to adoption to enable more integrated circuit (IC) design starts and faster time-to-market while increasing the investment in eBeam technologies throughout the semiconductor ecosystem. For more information, please email requests@ebeam.org or visit www.ebeam.org

The Fine Line: Autumn 2016
Videos for the eBeam Community

Shot Talk
Aki Fujimura, CEO of D2S, highlights several key developments at BACUS, including the eBeam Initiative Perception and Mask Maker surveys, recent updates on multi-beam mask writing and EUV, and a new generation of D2S GPU-acceleration solutions for semiconductor and photomask design and manufacturing. A Japanese version of the video can be found here.
Leo Pang, chief product officer of D2S, also recaps these developments in Chinese.

Tech Talk
Dr. David Lam, Chairman of Multibeam Corp., explains how eBeam technology can create the foundation for a more secure connected world by enabling IC-embedded security for Internet of Things (IoT) devices.

Perspectives
eBeam industry luminary Brian Grenon offers an analysis of the results of the eBeam Initiative’s second annual Mask Maker survey—including surprising findings on average data volumes, write times and turn-around times.

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Shot Talk: Aki Fujimura, D2S
Shot Talk: Leo Pang, D2S
Tech Talk: Naoya Hayashi, DNP

Perspectives: Aki Fujimura, D2S

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